OMB Control Number: 0694-0119 Expiration Date: September 30, 2024

DEFENSE INDUSTRIAL BASE ASSESSMENT: U.S. MICROELECTRONICS INDUSTRY



SCOPE OF ASSESSMENT

The U.S. Department of Commerce (DOC), Bureau of Industry and Security (BIS), Office of Technology Evaluation (OTE), is conducting a survey and assessment of the capabilities of the U.S. microelectronics industrial base to support the national defense as required in Section 9904 of the National Defense Authorization Act (NDAA) of Fiscal Year 2021 (15 USC §4654), in light of the global nature and interdependencies of the supply chain. The survey will collect information on the upstream materials and downstream end uses associated with microelectronics production.

This survey is not part of the application for funding under Section 9902 of the 2021 NDAA (15 USC \$4652). Individual survey responses will not affect your organization's eligibility and/or consideration for CHIPS Act or other government funding.

RESPONSE TO THIS SURVEY IS REQUIRED BY LAW

A response to this survey is required by law (50 USC §4555). Failure to respond can result in a maximum fine of \$10,000, imprisonment of up to one year, or both. Information furnished herewith is deemed confidential and will not be published or disclosed except in accordance with Section 705 of the Defense Production Act of 1950, as amended (50 USC §4555). Section 705 prohibits the publication or disclosure of this information unless the President determines that its withholding is contrary to the national defense. Information will not be shared with any non-government entity, other than in aggregate form. The information will be protected pursuant to the appropriate exemptions from disclosure under the Freedom of Information Act (FOIA), should it be the subject of a FOIA request.

Notwithstanding any other provision of law, no person is required to respond to nor shall a person be subject to a penalty for failure to comply with a collection of information subject to the requirements of the Paperwork Reduction Act unless that collection of information displays a currently valid OMB Control Number.

BURDEN ESTIMATE AND REQUEST FOR COMMENT

Public reporting burden for this collection of information is estimated to average 14 hours per response, including the time for reviewing instructions, searching existing data sources, gathering and maintaining the data needed, and completing and reviewing the collection of information. Send comments regarding this burden estimate or any other aspect of this collection of information to BIS Information Collection Officer, Room 6883, Bureau of Industry and Security, U.S. Department of Commerce, Washington, D.C. 20230, and to the Office of Management and Budget, Paperwork Reduction Project (OMB Control No. 0694-0119), Washington, D.C. 20503.

BUSINESS CONFIDENTIAL - Per Section 705(d) of the Defense Production Act

Previo	us Page Next Page
	Table of Contents
	Cover Page
П	Table of Contents
	General Instructions
IV	Definitions
1	Organization Information
2	Facilities and Operations
3a	Product Capability
3b	Production Capability
3c	Product End Use (Estimate)
3d	Primary Products
4	Outsourced Production
5a	Material and Input Suppliers
5b	Material and Inputs of Concern
6	Equipment Suppliers
7	Current and Future End Use
8	Supply Chain and Risk Management
9	Employment and Workforce Development
10a	Financials
10b	Research, Development, and Capital Expenditures
11a	Joint Ventures and Partnerships
11b	Technology Transfers
12	Competitive Factors
13	Long Term Investment and Development
14	Challenges
15	Certification
	BUSINESS CONFIDENTIAL - Per Section 705(d) of the Defense Production Act

Pre	evious Page
	General Instructions
	Your organization is required to complete this survey on the U.S. Microelectronics industrial base.
	You must complete the survey using the DOC/BIS template which is Microsoft Excel based and can be downloaded at [link TBA].
A	If you are not able to download the survey document, at your request BIS staff will email the Excel survey template directly to you.
	For your convenience, a PDF version of the survey and required drop-down content is available on the BIS website to aid internal data collection. DO NOT SUBMIT the PDF version of the survey as your response to BIS. Should this occur, your organization will be required to resubmit the survey in Excel format.
в	This survey is not part of the application for funding under Section 9902 of the 2021 NDAA (15 USC \$4652). Individual survey responses will not affect your organization's eligibility and/or consideration for CHIPS Act or other government funding.
	Any forecasts requested in this survey are understood to be speculative and for aggregate, statistical purposes.
C	Your organization has the option to provide a single Corporate level response or separate Business Unit/Division level responses for each of its semiconductor-related businesses.
	Note, if your organization is completing Business Unit/Division level surveys, any reference to "your organization" should be inferred as business unit or division. The reporting level must remain consistent throughout the survey, unless instructed otherwise.
D	Respond to every question. Surveys that are not fully completed will be returned for completion. Use the comment boxes to provide any information to supplement responses provided in the survey form. Make sure to record a complete answer in the space provided, even if the space does not appear to expand to fit all of the information.
	Survey inputs should be completed by typing in responses or by using a drop-down menu.
Е	Do not disclose any U.S. Government (USG) classified information in this survey form.
F	Submission of completed survey documents should be done using the designated Semiconductor Study inbox: SemiconductorStudy@bis.doc.gov
	Questions related to the survey should be directed to BIS survey support staff at <u>SemiconductorStudy@bis.doc.gov</u>
G	E-mail is the preferred method of contact.
	You may speak with a member of the BIS survey support staff by calling (202)-482-7808.
	For questions related to the overall scope of this assessment, contact <u>SemiconductorStudy@bis.doc.gov</u> or:
н	Jason D. Bolton Division Director, Industrial Studies Defense Industrial Base Division BIS/Export Administration/Office of Technology Evaluation 1401 Constitution Avenue, NW, Room 1093 Washington, DC 20230
	DO NOT submit completed surveys to Mr. Bolton's postal or personal email address. All surveys must be submitted electronically to [TBD].
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ection 2: Facilities and Operations

Identify each of your organization's facilities in operation since 2017, including facilities that are ideistandby, closed, or planned/expected (e.g. facilities that are or will be under construction or development). Then, provide the information related to each facility, as applicable. Note, for (g), (h), (i), and (j), you may specify the metric as applicable to your organization if the default metric is not appropulsing the dropdown menu option.

Facilities should include manufacturing facilities, design/R&D facilities, and distribution facilities. Do not include facilities that are solely engaged in sales and/or marketing activities. If you are reporting closed facilities, you only need to report facilities that have been closed within the past five pears.

For column (h), "optimal 2022 capacity" is the capacity level this facility would have in 2022 if your organization were able to make this change with no cost or lead time.

	1	Location		1			Ope	rations					Energy	Use					Future Ou	tlook
	(a)	(b)	(c)	(d)		(e)	(f)	(g)	(h)	(i)	(j)		3) -	(k)		(I)		(m)		(n)
Facility Name	City	State/Province	Country	Primary Op (select from di	eration rop-down)	Operating Status (select from drop-down)	Initial Year of Operations	2022 Capacity (if applicable)	Optimal 2022 Capacity (if applicable)	Expected 2027 Capacity (if applicable)	2022 Faci Total Ener Usage	lity E 'gy	Expected Fa 1 (selec	cility Energy L Through 2027 at from drop-do	Jse Change own)	Do you have an expand this fac the next 10	ny plans to cility within years?	Do you have a modernize the within the next	ny plans to his facility t 10 years?	Explain the future outlook for this facility, as applicable.
				1			(уууу)	Wafer Starts / Week	Wafer Starts / Week	Wafer Starts / Week	Megawatt H	iour (Change in	Reason for	the Change	(select from dr	op-down)	(select from a	rop-down)	
1						<u>ا ا ا</u>		(200mm equiv.)	(200mm equiv.)	(200mm equiv.)	(NIVII)	-	Energy Use		1	1 N		/		
2																				
3													1				1	1		
4				4		•							<u> </u>	1	•		<u> </u>			
5			Dropdowns:	•		Dropdown:					Dropd	own:		ropaown: Thango of one	ray courco					
6			- Core IP			- Operating	-				- Incre	ase	- HC	Ingrading of a	I BY SOULCE		\rightarrow			
8			- Electronic Design Au	utomation (EDA)		- Ceased operation	/Closed				- Decre	ease	- m	anufacturing	orocess			- /		
9			- Design Test and Ver	rification		- Planned/Expected					- NO CI	hange	- 6	Expansion of f	acility's			/		
10			 Front-End Manufact 	turing									ot	perations				*		
11			- Assembly and/or Pa	ckaging									- 0	Decrease in op	erations		Dropdov	n:		
12			- Equipment and Tool	ing									- (Other (Specify	here):		- Yes, in 1	L to 2 years		
13	L		- midlerials anu/or co - FMS/PCB Assembly	mponents				l					_			Τ	- Yes, in S	to 4 years		
14			- R&D														- Yes, in S	5 to 10 years		
16			- Distribution/Wareho	ousing													- No		-	
17			- Other															1		
18																				
19																				
20																				
21																				
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44																				
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46																				
47																				
48		1														1				
49		1																		
Comments		1		1			BUSINF	SS CONFIDENTIAL -	Per Section 705(d) of	f the Defense Produc	tion Act							1		
							DOOINL													

Previous Page Section 3a: Product Capability

Not spe	te: Sections 3a-3d are ir cification on your organ	nterconnected. In section ization's primary product	ns 3a-3c, you ar is within each ca	e asked to provide ategory, as applica	information on you ble.	r organization's ger	neral product capabilities,	production capabilities, and	d the estimated end use	for each category. In s	ection 3d, you are aske	d to provide more
	For each product categ however, you may spec	ory your organization des ify the metric as applicat	signs, manufact ble to your orga	tures, and/or distrit nization within the	outes, indicate the a dropdown menu.	ppropriate participa	ation type and provide the	corresponding product cat	egory information, as a	oplicable. For (f), (g), (h)), and (i), the default me	tric is nanometer (nm),
				(-)	(1.)	(-)	Pro	oduct Category Informati	on	(-)	(1-)	
	Product	Category	Particip	(a) pation Type m drop-down)	(b) Percent (%) of Production	(c) Current Lead Time	(d) Primary Material (select from drop-down)	(e) Primary Wafer Size (select from dron-down)	(†) Primary Technology Node	(g) Smallest Technology Node	(h) Largest Technology Node	(I) Expected Primary Technology Node in 2027
			(30/00/ 1/0	in alop downy	(By Revenue)	(Weeks)		(select nom arop down)	Nanometer (nm)	Nanometer (nm)	Nanometer (nm)	Nanometer (nm)
	1 Analog ICs											
Δ	2 Microcontroller and	Microprocessor ICs					▶					
<u>^</u>	3 Logic ICs			*		Dropdown:						
	4 Memory ICs		Dropdown:			- Amorphous S	Silicon	Dropdown:				
	5 Discretes		- Design Only	/		- Bulk Silicon		- 300mm				
	6 Optoelectronics		- Manufactu	re Only		- Silicon on Ins	sulator	- 200mm				
	7 Sensors & Actuator	'S	- Both Design	n and ivianutacture	2	- Silicon Germa	anium	- <=100mm				
	8 Printed Circuit Boar	rds	- Distribute t	Jniy		- Silicon on Saj	pphire	- Not Applicab	le			
	9 Equipment and Too	bling				- Silicon Carbio	nide					
	10 Intermediate or End	d Product				- Gallium Nitri	de					
-	11 Test and Design Ve	erification				- Indium Phos	ohide					
	12 Assembly and/or Pa	ackaging				- Antimonides						-
	13 Other	(Specify Here)				- Organic Tech	nologies					
	14 Other	(Specify Here)				- Carbon Base	d Technologies (e.g.					
	15 Utilei	(Specily Here)	I			nanotubes)						
	Comments					- Superconduc	ting Materials					
					BUSINES	S CONFIDENTIAL	Per Section 705(d) of t	he Defense Production A	Act			

Previous Page Section 3b: Production Capability

	For e	each product category your organization design	ns, manufa	ctures, an	d/or distribu	utes, <u>estin</u>	nate the pe	ercentage	of each fun	ction (i.e. D	esign, Mar	nufacture,	Assembly/	/Packaging	/Test, and I	Distribution) that is ca	rried out b	y the speci	fied locatior	ns (U.S. or	Non-U.S.) and by wi	hom (in-
	noua	e of outsourced). For the Design function, pre-	-existing in	DIOCKS SI		unieu sepe	aratery iror	in bour in-in	iouse and c	ui-sourceu	uesign.													
			1			Design					N	lanufactu	re			Assemb	oly/Packag	ging/Test			I	Distributio	n	
				U.S.	1		Non-U.S.			U	.S.	Non	-U.S.		L	.S.	Non	-U.S.		U	.S.	Nor	-U.S.	
		Product Category	In House	Outsourced	Pre-Existing Licensed IP Blocks	In House	Outsourced	Pre-Existing Licensed IP Blocks	Total	In House	Outsourced	In House	Outsourced	Total	In House	Outsourced	In House	Outsourced	Total	In House (Direct Sales)	Outsourced (Third-Party Sales)	In House (Direct Sales)	Outsourced (Third-Party Sales)	Total
	1	Analog ICs							0%					0%					0%					0%
	2	Microcontroller and Microprocessor ICs							0%					0%					0%					0%
А	3	Logic ICs							0%					0%					0%					0%
	4	Memory ICs							0%					0%					0%					0%
	5	Discretes							0%					0%					0%					0%
	6	Optoelectronics							0%					0%					0%					0%
	7	Sensors & Actuators							0%					0%					0%					0%
	8	Printed Circuit Boards							0%					0%					0%					0%
	9	Equipment and Tooling							0%					0%					0%					0%
	10	Intermediate or End Product							0%					0%					0%					0%
	11	Test and Design Verification							0%					0%					0%					0%
	12	Assembly and/or Packaging							0%					0%					0%					0%
	13	Other: N/A							0%					0%					0%					0%
	14	Other: N/A							0%					0%					0%					0%
	15	Other: N/A							0%					0%					0%					0%
	С	comments																						

Previous Page Section 3c: Product End Use (Estimate)

	For each product catego	ory your organization designs	s, manufactures,	and/or distribute	es, <u>estimate</u> the	percentage of I	revenue attribut	ed to each com	mercial and def	ense end use, v	vhere known.					
	Produc	t Category	Appliances/ Consumer Goods	Automotive	Commercial Aerospace	Healthcare/ Medical	Commercia Industrial	al End Use IT/Computers: Consumer Products	IT/Computers: Servers	Mobile Devices	Network Infrastructure	Other Commercial	Defense U.S. Defense	End Use Foreign Defense	Total	Unknown
	1 Analog ICs														0%	100%
	2 Microcontroller and	Microprocessor ICs													0%	100%
	3 Logic ICs														0%	100%
А	4 Memory ICs														0%	100%
	5 Discretes														0%	100%
	6 Optoelectronics														0%	100%
	7 Sensors & Actuators	3													0%	100%
	8 Printed Circuit Board	ds													0%	100%
	9 Equipment and Too	ling													0%	100%
	10 Intermediate or End	Product													0%	100%
	11 Test and Design Ve	rification													0%	100%
	12 Assembly and/or Pa	ickaging													0%	100%
	13 Other: N/A														0%	100%
	14 Other: N/A														0%	100%
	15 Other: N/A														0%	100%
_																
в	Overall, how confident is your organization in estimating its product end-uses on a scale of 1 (Not at all confident) to 5 (Extremely confident)? Select the closest number from the scale in the dropdown.															
	Comments															
					BUSINESS	CONFIDENTI	AL - Per Sectio	on 705(d) of the	Defense Prod	uction Act						

Dropdown:

- 1 - Not at all confident - 2 - Low confidence

- 3 - Moderate confidence

- 4 - Great confidence

- 5 - Extremely confident

P	revious Page ection 3d: Prima	ry Products												Next Page
	For each produ	ct category your organization de	signs, manufa	actures, and/or distributes	, list up to th	e three primary product type	es with the highes	st gross revenue and p	rovide the corresponding p	product type information,	as applicable.			
	For (g), (h), (i),	and (j), the default metric is nane	ometer (nm), I	nowever, you may specify	the metric a	s applicable to your organiz	ation within the c	Iropdown menu.						
								Pro	duct Type Information					
				(a)		(b)	(c)	(d)	(e)	(f)	(g)	(h)	(i)	(j)
		Product Category	Prin (sele	nary Product Type ct from drop-down)	Р	roduct Description	Percent (%) of Category's Production (By Revenue)	Current Lead Time (Weeks)	Primary Material (select from drop-down)	Primary Wafer Size (select from drop-down	Primary Technology Node	Smallest Technology Node	Largest Technology Node	Expected Primary Technology Node in 2027
			1	-					,	\	Nanometer (nm)	Nanometer (nm)	Nanometer (nm)	Nanometer (nm)
	1 Analog ICs		2											
	2 Microcontro	oller and Microprocessor ICs	1 2 3											
	3 Logic ICs		1 2 3											
	4 Memory IC	s	1 2 3					Dropdown: - Amorphous - Silicon Bulk		- 300mm - 200mm	vn:			
	5 Discretes		1 2 3 1					 Silicon Silicon on Silicon Germaniu Silicon on Sapphi 	Insulator - m re	- 150mm - <=100m - Not Ap	nm plicable			
A	6 Optoelectro	onics	1 2 3					- Silicon Carbide - Gallium Arsenide - Gallium Nitride						
	7 Sensors &	Actuators	1 2 3					- Indium Phosphide - Antimonides - Organic Technolo - Carbon Based Technolo	e Igies					
	8 Printed Cir	cuit Boards	1 2 3					- Superconducting - Other (Specify He	Materials re)					
	9 Equipment and Tooling													
	10 Intermedia	te or End Product	2 3											
	11 Test and D	esign Verification	2 3											
	12 Assembly a	and/or Packaging	2 3											
	13 Other: N/A		2 3											
	14 Other: N/A		2 3											
_	15 Other: N/A		2 3											
┝	Comments					BUSINESS CONF	IDENTIAL - Per	Section 705(d) of the	Defense Production Act	1				
-														
				+										
		Analog ICs: - General Purpose Analog - Amplifiers/Comparators - Interface - Power Management - Signal Conversion - Application Specific Ana - Consumer - Computer	log	Microcontroller and Microprocessor ICs: - MOS MPU - MOS MCU - General Purpose MC - Automotive MCU - Smart Card MCU - MOS DSP	υ	Logic ICs: - Digital Bipolar - MOS General Purpose I - MOS Gate Arrays - MOS Standard Cells - MOS Toipslay Drivers - MOS Touch Screen Con - MOS Special Purpose Lo - Consumer	Logic Itrollers ogic	Dropdowns: Memory ICs: - MOS DRAM - MOS SRAM - MOS Mask PROM & EPROM - NOR Flash Memory - NAND Flash Memory - Other Memory	Discretes: - Diodes - Small Signal Switching Trans - Power Trans - Rectifiers - Thyristors - All Other Dis	and - Dist - Dist - Lan nsistors - Opt - CCC - CCM - CCM - Ott - Infr	electronics: Jlays ps o Couplers & Isolators ical Switches & Other Image Sensos DS Image Sensors er Optoelectronics ared	Sensors & A - Temperatu - Pressure S - Accelerati Sensors - Magnetic I - Actuators	ictuators: ure & Other Sensors ensors on & Yaw Rate Field Sensors	
	- Computer - Communications - Automotive - Industrial & Others					- Computer & Peripheral - Communication - Automotive - Multipurpose & Other	ls			- Las - Las - Ligh	er Fickup er Transmitter it Sensors			

evio	ous Page								Next Page	
tio	on 4: Outsourced Production									
ea J.S	ach production function your organization outsource. S. and physically located outside of the U.S. Next,	es (i.e. Design, Manutacturin list up to the ten service prov	g, Assembly/Packaging/Tes viders most important for you	t, and/or Distribution), indica ur organization's continued	ate the tota operations	il number of service p in each of respective	providers your organ e functions and provi	ization us ide the cor	es both physically located in rresponding information, as	
ica	able.			· ·	·					
)	Outsourced Design (IP Licensing)									
	Total Number of Providers Servicing in the U.S.		1	Total Number of Provider	s Servicino	Outside of the U.S.				
-			1		o o o r rioing					
	Design/IP Provider Name	Primary Location of Service Performance	Primary Product	Percent (%) of Primary Product Dependent	Percer	nt (%) of Products	Primary Reaso	on for Selection	Availability of Alternative Service Providers	
1	Designin Provider Hame	(select from drop-down)	(select from drop-down)	on Provider	Dop	on Provider	(select from drop	o-down)	(select from drop-down)	
	1									
ŀ	2		+			Drondow	n.	-	<u> </u>	
ŀ	4		Dropdown:			- Financial	l Consideration	-	Dropdown:	
Ľ	5		Dropdown will populate			- Technica	Il Specification		- Yes - U.S. Alternate Availal	ible
F	6					- Existing - Delivery	Time		- Yes - Only non-U.S. Alterna	ate Availab
ŀ	7					- Proximit	У	-		
ŀ	9					- Quality - Export C	ontrols	H		
Ľ	10									
3)	Outsourced Manufacturing									
	Total Number of Providers Servicing in the U.S.		1	Total Number of Provider	Servicing	Outside of the U.S.				
	Total Number of Providers Servicing III (IIE 0.5]	Total Number of Providers	a der vicility	outside of the 0.5.				
ſ	Manufacturing Provider Name	Primary Location of Service Performance	Primary Product	Percent (%) of Primary Product Dependent	Percer	nt (%) of Products	Primary Reaso	on for Selection	Availability of Alternative Service Providers	
L	Manalaotaning Providor Hamo	(select from drop-down)	(select from drop-down)	on Provider	Det	on Provider	(select from drop	o-down)	(select from drop-down)	
	1						↓			
ŀ	3		*			Dropdown:			Drandaura	
	4		Dropdown: Dropdown will populate			- Financial Conside	ration		- None - Sole Global Source	
ŀ	5		from answers in tab 3a			- Existing Relations	hip		- Yes - U.S. Alternate Available	A
ŀ	7					- Delivery Time			- Yes - Uniy non-U.S. Alternate	Available
Ľ	8	L				- Proximity - Quality				
	9					- Export Controls				
(Outsourced Assembly/Packaging/Test	-	-							
	Total Number of Providers Servicing in the U.S.:			Total Number of Providers	s Servicing	Outside of the U.S.:				
ſ		Primary Location of Service	Primary Product	Percent (%) of Primary	Percer	nt (%) of Products	Primary Reaso	on for	Availability of Alternative	
	Assembly/Packaging/Test Provider Name	Performance (select from drop-down)	Category (select from drop-down)	Product Dependent on Provider	Dep	endent Overall on Provider	Service Provider S (select from drop	Selection o-down)	Service Providers (select from drop-down)	
	1		, , ,					,		
ŀ	2					Dropdown:		1	Dropdown:	
ŀ	4		Dropdown:			- Financial Consid	leration		- None - Sole Global Source	
Ľ	5		from answers in tab 3a			 Technical Specification Existing Relation 	ication		 Yes - U.S. Alternate Available Yes - Only non-U.S. Alternate 	e e Available
ŀ	6					- Delivery Time	· •			
ŀ	8	<u> </u>		J		- Proximity				
F	9					- Export Controls				
Ľ	10									
D)	Outsourced (Third-Party) Distribution									
	Total Number of Providers Servicing in the U.S.:			Total Number of Providers	s Servicing	Outside of the U.S.:				
Г		Primary Location of Service	Primary Product	Percent (%) of Primary	Percer	nt (%) of Products	Primary Reaso	on for	Availability of Alternative	
	Distribution Provider Name	Performance	Category	Product Dependent	Dep	endent Overall	Service Provider	Selection	Service Providers	
ŀ	1	(select from drop-down)	(select from drop-down)	on Provider		on Provider	(select from drop	o-down)	(select from drop-down)	
t	2					_	1 🕴 👘			
F	3	Dre	opdown:			Dropdown: Financial Consi	deration		Dropdown:	
ŀ	4	Dro	opdown will populate			- Technical Spec	ification		 - None - Sole Global Source - Yes - U.S. Alternate Availab 	ble
t	6	fro	m answers in tab 3a			- Existing Relation	onship		- Yes - Only non-U.S. Alterna	ate Available
F	7		F			- Proximity				
ŀ	8					- Quality	_			
t	10					- Export Control	5			
f	Commente					L				
ſ	Comments									
1		BUSINESS	S CONFIDENTIAL - Per Sec	ction 705(d) of the Defens	e Product	ion Act				

Pre	evious Page												Next Pag
Se	ction 5: Material	and Input Suppliers											
For inp	r each material an ut category your o	d input category, provide the to organization sources, as applica	atal number of su able. Note, estin	uppliers your organiza nates for lead time and	tion uses for its fac d inventory levels a	cilities lo are accep	cated in the U.S. (Part ptable.	A) an	d its facilities located	outside of the U	.S. (Part B); then, provid	e the corresponding informa	ation for each material and
	A) U.S. Facilities	6											
	м	aterial and Input Category	Total Suppliers	Total # of Suppliers Physically Located in the U.S.	Percent (%) Supp by U.S Based Suppliers	blied I I (se	Primary Reason for Supplier Selection elect from drop-down)	Ava (sele	ilability of Alternate Suppliers act from drop-down)	Lead Time (Weeks)	2018 Inventory Level: (Weeks of Supply)	s 2022 Inventory Levels (Weeks of Supply)	Optimal Inventory Level: (Weeks of Supply)
	1 Wafer												
	a Bulk Silicoi	n (Specify Here)	-										
	c Other	(Specify Here)			Dr	opdown	:		*				
	2 Photoresist				- Fi	inancial (Consideration		Dropdown:	abal Course			
	4 Gases		1		- T	echnical	Specification	-	- Yes - U.S. Alter	nate Available		-	
	5 Wet Chemica	ls			- Ei	xisting R	elationship		- Yes - Only non-	U.S. Alternate A	vailable		
А	6 CMP Slurry		_		- D - P	roximity	,	_					
	8 ALD/CVD Ma	terials			- 0	uality		_					
	9 Electroplating	Metals			- E:	xport Co	ontrols						
	10 Spin-on Diele	ctrics			- 0	ther							
	12 Packaging Su	bstrates											
	13 Ceramics												
	14 Bonding Wire	aterial	-										
	16 Encapsulation	Resins											
	17 Other	(Specify Here)											
	18 Other	(Specify Here)											
	20 Other	(Specify Here)											
	B) Non-U.S. Faci	ilities											
	м	aterial and Input Category	Total Suppliers	Total # of Suppliers Physically Located in the U.S.	Percent (%) Supp by U.S Based Suppliers	olied I I (se	Primary Reason for Supplier Selection elect from drop-down)	Ava (sele	ilability of Alternate Suppliers act from drop-down)	Lead Time (Weeks)	2018 Inventory Level: (Weeks of Supply)	2022 Inventory Levels (Weeks of Supply)	Optimal Inventory Level (Weeks of Supply)
	1 Wafer												
	a Bulk Silico	n (Specify Here)											
	c Other	(Specify Here)			Dropdov	vn:			*				
	2 Photoresist				- Financia	al Consid	deration		Dropdown:	Course.			
	3 Photomask 4 Gases		1		- Technic	al Specif	fication		- None - Sole Global 3 - Yes - U.S. Alternate	Available		-	
	5 Wet Chemica	ls			- Existing	, Relatioi V Time	nsnip		- Yes - Only non-U.S.	Alternate Availa	ble		
в	6 CMP Slurry		_		- Proximi	ity							
	8 ALD/CVD Ma	terials			- Quality								
	9 Electroplating	Metals			- Export	Controls							
	10 Spin-on Diele	ctrics	-		- Other								
	12 Packaging Su	bstrates											
	13 Ceramics												
	14 Bonding Wire	aterial	-										
	16 Encapsulation	Resins											
	21 Other	(Specify Here)											
	22 Other 23 Other	(Specify Here)	-										
	24 Other	(Specify Here)											
	Comments												
				E	USINESS CONFI	DENTIA	L - Per Section 705(d)) of th	e Defense Producti	on Act			

Previous Page Section 5b: Material and Inputs of Concern

Fo	each material and input cate	ory that your organization sou	rces, name up	to three of th	ie most esser	ntial material a	nd inputs that your o	rganization has diffici	ulty acquiring. V	Vhen reporting the su	pplier's country, prov	ide the country	where the sup	plier is physica	ally located not	the country where	the supplier's headquarte	rs are located.
	Material and Input Category	Name of Material or Input of	Level of E	Difficulty to	Primary Pro	duct Affected	I	Primary Supplier		Se	condary Supplier		Lead Time	Inven	ory Levels (We	eeks of Supply)	Do you antici mate	pate difficulties to acquire this ial/input in the future?
		Concern	(select from	drop-down)	(select from	drop-down)	Supplier Name	Supplier Country	Percent (%) Supplied	Supplier Name	Supplier Country	Percent (%) Supplied	(Weeks)	2018	2022	Optimal	Level of Dificulty	Explain
1	Wafer	3																
2	Photoresist	2			Dropdow	vn:												
3	Photomask	1 2 3	Dropdown - None	n:	Dropdow from ans	vn will populat wers in tab 3a	e										Dropdown:	
4	Gases	1 2 3	- Minor - Moderat	e													- Minor - Moderate	
5	Wet Chemicals	1 2 3	- Great - Extreme														- Great - Extreme	
6	CMP Slurry	1 2 3																
7	PVD Targets	1 2 3																
8	ALD/CVD Materials	1 2 3																
9	Electroplating Metals	ating Metals 1 2 3 -																
10	Spin-on Dielectrics	I I																
A 11	Leadframes	1 2 3																
12	Packaging Substrates	1 2 3																
13	Ceramics	1																
14	Bonding Wire	1																
15	Die Attach Material	1 2 3																
16	Encapsulation Resins	1																
17	Other: N/A	1 2 3																
18	Other: N/A	1 2 3																
19	Other: N/A	1 2 3																
20	Other: N/A	1 2 3																
21	Other: N/A	1 2 3																
22	Other: N/A	1 2 3																
23	Other: N/A	1 2 3																
24	Other: N/A	1 2 3																
	Comments																	
							BUS	SINESS CONFIDENT	IAL - Per Sect	on 705(d) of the Det	ense Production Ac	:t						

Previous Page Section 6: Equi	pment Suppliers														Next Page	
For each equipm	nent category, provide the total number	er of suppliers yo	our organization uses for its	facilities located in the	J.S. (Part A) and its fa	cilities located	outside of the	e U.S. (Part B); and provide	the corresponding inform	nation, as	s applicable.				1
																1
A) U.S. Facil	lities Equipment Category	Total Number of Suppliers	Primary Equipment Supplier Name	Primary Supplier Country	Description/ Specific Tool	Average	Lead Time by (Weeks) (as	Equipment V s applicable)	Vafer Size	Primary Reason for Supplier Selection	Cha	Primary Illenge/Concern	Availability of A Supplier	Alternate	Additional Comments	
4 Design 7						<=150mm	200mm	300mm	No Size	(select from drop-down)) (select	t from drop-down)	(select from dro	op-down)		1
2 Depositi	on													_		1
3 RTP and 4 Lithogra	d Oxidation Diffusion phy															
A 5 Photores	sist Processing								Dropdown:)ropdown:				
6 Material 7 Diffusion	Removal and Cleaning /lon Implantation (doping)								 Financial Col Technical Sp 	ecification		Aging equipment			Dropdown:	
8 Process	Control (Metrology and Inspection)								- Existing Rela	itionship	- 1	Maintenance Energy Cost			- Yes - U.S. Alternate Available	
10 Other W	afer Fabrication Equipment								- Proximity	ie .	-	Purchase Cost	C		- Yes - Only non-U.S. Alternate A	vailable
11 Test and 12 Assembl	d Related Equipment								- Quality	rols		Obsolescence	Controis			
13 Other	(Specify Here)								- Other	-	-	Throughput Other (Specify Her	· 0)			
14 Other 15 Other	(Specify Here)								1		<u> </u>	Other (Specify Her	e)			
B) Non-U.S.	Facilities															
	Equipment Category	Total Number of Suppliers	Primary Equipment Supplier Name	Primary Supplier Country	Description/ Specific Tool	Average	Lead Time by (Weeks) (as	Equipment V s applicable)	Vafer Size	Primary Reason for Supplier Selection (select from drop-down)	Cha (select	Primary Illenge/Concern t from drop-down)	Availability of A Supplier (select from dro	Alternate rs op-down)	Additional Comments	
1 Design T	Tools and EDA Software						2001111	00011111	110 0120					$\overline{\ }$		
3 RTP and	on d Oxidation Diffusion															
4 Lithogra	phy sist Processing								ropdown:	-	Dro	opdown:				
6 Material	Removal and Cleaning							-	Financial Cons	sideration -	- Ag - Mi	ging equipment aintenance			Dropdown:	·
7 Diffusion 8 Process	n/lon Implantation (doping) Control (Metrology and Inspection)								Existing Relati	ionship	- En	nergy Cost			- None - Sole Global Source	
9 Manufac	cturing Automation								Delivery Time Proximity	•	- Pu - Re	archase Cost egulation/Export Co	ontrols		- Yes - Only non-U.S. Alternate A	wailable
10 Other W 11 Test and	arer Fabrication Equipment							-	Quality	. –	- Ot	bsolescence				
12 Assembl	ly Equipment	_							Export Contro Other	bis	- Ot	ther (Specify Here)				
14 Other	(Specify Here)															
15 Other	(Specify Here)															
Export Cont	rois							_								
1 What is	your organization's outlook for equipn	ment supply over	the next three years?							- No impact						1
										- Great Impact - Posit	tively					
								-		- Great Impact - Nega - Moderate Impact - F	atively Positively	y				1
2 Indicate	the impact of export controls on your	production level	s and provide an explanation	on below.						 Moderate Impact - Noderate Impact - Noderate Impact 	Negative	ły				
								4		- Low Impact - Negati	ively					
3 Have ex	port controls affected your organization	on's equipment a	cquisition processes? If ye	s, provide an explanatio	n below.					Dropdown:						l
								1		 Yes, positively Yes, negatively No 						
4 Has you	r organization experienced loss of sal	les opportunities	due to export controls? If y	es, provide an explanat	ion below.					·						
																l
Comments				BUSIN	ESS CONFIDENTIAL	- Per Section	705(d) of the	Defense Pro	oduction Act							

ection 7:	Current and Future End Use

For each commercial and defense end use segment that your organization supports, provide the following estimates for both current end uses (Part A) and future/expected end uses in the next five and ten years (Part B):

(a) the percentage (%) of your organization's total revenue attributed to the end use overall, (b) the percentage (%) of (a) attributed to U.S. sales in the end use, (c) the primary non-U.S. country of end use, (d) the total percentage (%) of (a) attributed to its primary country of end use, and (e) the percentage (%) of the end use segment using advanced packaging.

Example: Your organization's total revenue is split 50/50 between the Automotive and Commercial Aerospace end uses. Of the percentage of total revenue attributed to each respective end use, 50% of the Automotive and 100% of the Commercial Aerospace end uses acrospace end use total revenue is attributed to U.S. sales. Overall, 75% of your organization's total revenue is attributed to U.S. sales across its end uses.

	(a)	(b)
Commorpial End Lloo	Percent (%) of Total	Percent (%) of End Use Total Revenue
Commercial End Ose	Revenue	from U.S. Sales
Automotive	50%	50%
Commercial Aerospace	50%	100%
Total Commercial	100%	75%

Next, in each Total Commercial and Total Defense row in both Part A (current end uses) and Part B (future/expected end uses), identify the primary non-U.S. country of respective total end use, the percentage (%) of total revenue attributed to the primary country, and the percentage (%) of the respective total end use using advantaged packaging.

	A) Current End Use (Estimated)	,	`		(1)					,	l,
		(a)		(b)	((C)	(d)	(6	3)
	Commercial End Use	Percent (Rev	%) of Total enue	Percent (% Total Re U.S	6) of End Use evenue from . Sales	Primary Non-U.S. (select from	Country of End Use a drop-down)	Percent (%) of Revenue to P	f End Use Total rimary Country	Percent (%) of Advanced	End Use Using Packaging
	Appliances/Consumer Goods										
	Automotive										
	Commercial Aerospace										
	Healthcare/Medical										
	Industrial										
	IT/Computers - Personal and Consumer Products										
Δ	IT/Computers - Servers										
	Mobile Devices										
	Network Infrastructure										
	Other										
	Total Commercial (Current)		9/		09/			1			
			70		0%						
	Defense End Use	Percent (' Rev	%) of Total enue	Percent (% Total Re U.S	6) of End Use evenue from 5. Sales	Primary Non-U.S. (select from	Country of End Use a drop-down)	Percent (%) of Revenue to P	f End Use Total rimary Country	Percent (%) of Advanced	End Use Using Packaging
	U.S. Defense										
	Foreign Defense										
	Total Defense (Current)	0	%		0%						
								1		1	
	B) Future/Expected End Use (Estimated)										
			a)		(b)		(c)		d)	(6	e)
	Commercial End Use	Percent (Rev	%) of Total enue	Percent (% Total Re U.S	6) of End Use evenue from 5. Sales	Primary Non-U.S. (select from	Country of End Use a drop-down)	Percent (%) of Revenue to P	f End Use Total rimary Country	Percent (%) of Advanced	End Use Using Packaging
		2027	2032	2027	2032	2027	2032	2027	2032	2027	2032
	Appliances/Consumer Goods										
	Automotive										í –
	Commercial Aerospace										
	Healthcare/Medical										
	Industrial										
	IT/Computers - Personal and Consumer Products										
в	IT/Computers - Servers										
	Mobile Devices										
	Network Infractructure										
	Othor										
	Total Commercial (Euture/Europated)	0.9/	0.9/	0.9/	00/		1				
	Total Commercial (Future/Expected)	0%	0%	0%	0%						·
	Defense End Use	Percent (Rev	%) of Total enue	Percent (% Total Re U.S	6) of End Use evenue from . Sales	Primary Non-U.S. (select from	Country of End Use a drop-down)	Percent (%) of Revenue to P	f End Use Total rimary Country	Percent (%) of Advanced	End Use Using Packaging
		2027	2032	2027	2032	2027	2032	2027	2032	2027	2032
	U.S. Defense										
	Foreign Defense										
	Total Defense (Future/Expected)	0%	0%	0%	0%						
	Comments						•				
			DIIGINESS		IAL Por Soctio	n 705(d) of the Defense	a Production Act				

Pre	evious Page								Next Page]
Se	Citica 8: Supply Chain and Risk Management									
	Does your organization have a supply chain risk management (SCRM) program?									
What software, subscriptions, and/or tools do your organization use to help anticipate and monitor supply chain risks (e.g. disruptions, bottlenecks, delays, etc.)?									Dropdown:	
- Yes - No									- Yes - No	
	What protocols do your organization have in place to n	nitigate supply chain risks (e.g. bottle	enecks, d	lisruptions,	delays, etc)? Please explain.					
_										
	For the below supply chain practices or features, ident	fy how your organization's activities	(a) have	changed s	ince 2017 and (b) are expected to change	e from 2022 to	2027.			
	ltem	Change	since		Explanation of Changes	Expected (Changes	Evol	lanation of Anticipated Changes	
		201	17		Explanation of Ghanges	from 2022	to 2027	LAPI	anation of Anticipated Unanges	
	1 Redundancy of suppliers 2 Localized supply chains					+ •			٦	
	3 Target inventory levels		Dropdo	own:			Dropd	own:		
в	4 Length of supplier contracts		- Increa	se			- Increa	se		
	5 Length of customer contracts		- Decrea	ange			- No Ch	ange		
	6 Use of non-cancellable supplier contracts									
	8 Number of supply chain management workers									
	9 Use of distributors									
	10 Use of supply chain modeling and forecasting									
	11 Use of shipping and receiving ports									
	12 Other (Spe	cify Here)								
_	13 Other (Spe	cify Here)								
	Please describe your organization's general method fo	r maintaining inventory levels of criti	ical mater	rials:						
	In the event of an unexpected shutdown, how long wou	Ild it take your organization to resum	ne normal	l levels of p	roduction? (select from dropdown)					
С	Identify the three materials/inputs for which your organ	zation expects to have the greatest	increase	in usage/d	emand in the next 10 years:					Dropdown:
	Material/Input				Explanation					- Less than 2 weeks - About 2 weeks
	1									- About 4 weeks
	2									- About 8 weeks
L	3									- About 6 months - More than 6 months
Comments										
BUSINESS CONFIDENTIAL - Per Section 705(d) of the Defense Production Act							1			

	ous Page ion 9: U.S. Employment and Workforce	Development								Next Page	
Segment CHO Segment CHO In a contract of the South and PC of Libbar to FFE weightings and contractions of your U.S. Excites for each your to FFE weightings and contractions of your U.S. Excites for each your to FFE weightings and contractions of your U.S. Excites for each your to FFE weightings and contractions of your U.S. Excites for each your to FFE weightings and contractions of your U.S. Excites for each your to FFE weightings and contractions of your U.S. Excites for each your to FFE weightings and contractions of your U.S. Excites for each your to FFE weightings and contractions of your U.S. Excites for each your to FFE weightings and contractions of your U.S. Excites for each your to FFE weightings and contractions of your to FFE weightings and your to FFE weightings	pond to the questions below pertaining to	employment and w	orkforce devel	opment in 1	the U.S.						
	Employment Totals										
Data Data <thdata< th=""> Data Data <thd< td=""><td>Record the total number of U.S. Citizen an percentage of non-U.S. Citizen FTE emplo</td><td>d non-U.S. Citizen oyees and contracto</td><td>full time equive ors that are H1-</td><td>alent (FTE) B Visa Hol</td><td>) employees and Iders. Then, ind</td><td>d contractors at yo cate the annual tu</td><td>ur U.S. facilities for rnover rate for U.S.</td><td>each year from 20 Citizen and non-L</td><td>)17 to present, a J.S. Citizen FTE</td><td>s well as the employees.</td></thd<></thdata<>	Record the total number of U.S. Citizen an percentage of non-U.S. Citizen FTE emplo	d non-U.S. Citizen oyees and contracto	full time equive ors that are H1-	alent (FTE) B Visa Hol) employees and Iders. Then, ind	d contractors at yo cate the annual tu	ur U.S. facilities for rnover rate for U.S.	each year from 20 Citizen and non-L)17 to present, a J.S. Citizen FTE	s well as the employees.	
U.S. Distant Internal Internal Internal Internal IS Control Second Distantiant Internal Internal <td></td> <td></td> <td></td> <td>2017</td> <td>7 201</td> <td>8 2019</td> <td>2020</td> <td>2021</td> <td>2022</td> <td>Annual Turnover Rate</td>				2017	7 201	8 2019	2020	2021	2022	Annual Turnover Rate	
Month J. Control Month J. Control<	1 U.S. Citizen										
Instrume	2 Non-U.S. Citizen									-	
************************************	b % from U.S. Arms Embargoed Cou	intries*								- 1	
table in the second balance and provide later balance	*As of the release of this survey this inc	cludes: Afghanistan, E	lelarus, Burma, (Cambodia, C	Central African Re	oublic, China (PRC),	Congo, Cuba, Cyprus,	Eritrea, Haiti, Iran,	Iraq, Lebanon,	-	
An and a base in a consistence of a consistence of a line equivalence of ATT is equivalence by a consistence of a consis	Educational Qualifications	outh Sudan, Sudan, S	yna, venezuela,	and Zimbab	owe						
alarge associated with incruiting or matching employees at activ addicatoral level. Image: control incruiting or matching employees at activ addicatoral level. Pervany uso This Explanation of Chalaroge Reculting Mantabing Education Recurrent incruiting or matching employees at activ addicatoral level. Image: control incruiting or matching employees at activ addicatoral level. Image: control incruiting or matching employees at activ addicatoral level. SiA A Image: control incruiting or matching employees at activ addicatoral level. Image: control incruiting or matching employees at activ addicatoral level. Image: control incruiting or matching employees at activ addicatoral level. SiA A Image: control incruiting or matching employees at activ addicatoral level. Image: control incruiting or matching employees at activ addicatoral level. Image: control incruiting or matching employees at activity addicatoral level. Image: control incruiting or matching employees at activity addicatoral level. Image: control incruiting or matching employees at activity addicatoral level. Image: control incruiting or matching employees at addicatoral level. Image: control incruiting or matching employees at addicatoral level. Image: control incruiting or matching employees at addicatoral level. Image: control incruiting or matching employees at addicatoral level. Image: control incruiting or matching employees at addicatoral level. Image: control incruiting or matching employees at addicatoral level. Image: control incruiting or matching employees at addicatoral level. I	Pacard the total number of current and av	posted full time or	uivalant (ETE)	mployoog	by qualification	Thon identify the	primary job titlo ag	pociated with each	h aducational law	ol and koy	
2022 2027 2032 Privary Job Tile Peptinention of Chalarges RecruitingMaintaining Education Requirement Image: Stand Collage Image: Stand C	challenges associated with recruiting or maintaining employees at each educational level.										
2022 2027 2027 2027 2027 2027 Printy Joh Tile Laplanation of Dialespise RecruitingMaintaining # School/SDD Image: School/SDD											
Election Requirement in the series of the series and the series an	2022 2027 2032 Primary Job Title Explanation of Challenges Recruiting/Maintaining										
	2 Education Requirement										
Initial consistence Initial consistence <thinitial consistence<="" th=""> Initial consistence</thinitial>	gh School/GED										
B.B.A. Image: Control in the control of the contro	Certification or Partial College										
S.R.A. Image: Control Image: Control Image: Control Image: Control et 1613 Conceptional Category: Bit your Organization employs, Indicate the minimum educational qualification required, the average saley, and the average saley. Take its control the minimum educational qualification required, the average saley. Take its control the minimum educational qualification required, the average saley. Take its control the minimum educational qualification required, the average saley. Take its control the minimum educational qualification required, the average saley. Take its control the minimum educational qualification required (the minimum educational qualification required, the average saley. Take its control the minimum educational qualification required (the minimum educational qualification required). The average saley. Take its control the minimum educational qualification required (the minimum educational qualification required). The average saley. Take its control the minimum educational qualification required (the minimum educational qualification required). The average saley. Take its control the minimum educational qualification required (the education educ	3.S./B.A.										
Control Control Control Control Control Control Control Control <td>M.S./M.A.</td> <td></td> <td></td> <td></td> <td></td> <td></td> <td></td> <td></td> <td></td> <td></td>	M.S./M.A.										
An order rech coccipation category that your organization employs, indicate the minimum educational qualification required, the average stating salary, and the average stating salary. Then, record the rech coccipational Categories Occipational Categories Minimum Educational Qualification Requirement (Qualification Requirement (Qualif	Doctorate										
e eko accupation category that your organization employs, indicate the minimum educational qualification required, the average salar), and the average stating salary. Then, record the met of ourant employees and number of current employees and number of scarce (2022) and in the next 10 years (2022) in each category. Occupational Categories Minimum Educational expected in the next 30 years (2022) and in the next 10 years (2022) is each category. Corrent interest 30 years (2022) and in the next 30 years (2022	Vacancies										
Comparison Call (3)	Occupational Categories	or current vacancie	Minimum E	Educationa	Average	Salary Starting St	e Current	Current	Total Number (Ex	er of Employees	
ninalacturg signeres, sometis, real			(select from	n dropdown	n) (\$)	(\$)	2022	2022	2027	2032	
Arr Education Requirement Arr Education Are Edu	C Production Line Operations Dropdown:										
ang and usang Usan				- No Edu	ucation Requirem	ent					
amaion TechnologyComputing	Testing and Quality Control			Certific	cation or Partial C	ollege					
isex. Administrative, and Management - Octorate Image: Control of Control C	Information Technology/Computing			- B.S./B. - M.S./N	А. Л.А.						
Inter (Specify Here) Inter (Specify Here) Inter index your cranitation's level of difficulty running workers with title industry experience. Explant: Internation's level of tifficulty running workers with title industry experience. Explant: Icade which of the following methods you currently emply, then rank the top five by their value to your organization's recruitment/training programs: Explanation Internatings Forgram Use Rank Explanation Cutreact to K-12 Partemative the industry experience. Internative the industry experience. Internative the industry experience. Partemative the following methods you currently emply, then rank the top five by their value to your organization's recruitment/training programs: Explanation Internative the following methods you currently emply. Partemative their industry experience. Explanation Partemative their industry experience. Program Internative their industry experience. Internative their industry experience. Partemative their industry experience. Program Internative their industry experience. Internative their industry experience. Partemative their industry experience. Internative their industry experience. Internative their industry experience. Internative their industry experient that difficultry in the full unre?	Sales, Administrative, and Management			- Doctor	rate						
Internation (specify Here) Explain: Internation (specify Here) Use Rark Program Use Rark Internation (specify Here) Use Rark Partnernation (specify Here) Use Rark Internation (specify Here) Use Rark Partnernation (specify Here) Use Rark Partnernation (specify Here) Dropdown: Specify Here) Partnernation (specify Here) No Specify Here) Ontreact for (specify Here) No Specify Here) Other (Specify Here) Specify Here) Specify Here) Internation (specify Here) Specify Here) S	Other (Specify Here)			-				1	1		
The provide the specific computer of a specific computer of the specif	Other (Specify Hare)								1	+	
Intervalue of a social of the second of the	Workforce Development										
Industry training workers with tittle industry experience. Image: Constraint of the following methods you currently employ, then rank the top five by their value to your organization's recruitment/training programs: Internships Vex Rank Explanation Outreach to K-12 Image: Constraint of the top five by their value to your organization's recruitment/training programs: Constraint of K-12 Partnership with local community college Image: Constraint of K-12 Image: Constraint of K-12 Partnership with local community college Image: Constraint of K-12 Image: Constraint of K-12 Partnership with local community college Image: Constraint of K-12 Image: Constraint of K-12 Partnership with local community college Image: Constraint of K-12 Image: Constraint of K-12 Partnership with local anivership Image: Constraint of K-12 Image: Constraint of K-12 Partnership with local anivership Image: Constraint of K-12 Image: Constraint of K-12 Partnership with local anivership Image: Constraint of K-12 Image: Constraint of K-12 Partnership with local American Job Centers Image: Constraint of K-12 Image: Constraint of K-12 Other (Specify here) Image: Constraint of K-12 Image: Constraint of K-12 Outher of constrainting and retaining the nec	Indicate your organization's level of difficul	Ity			E e la	in.					
index which of the following methods you currently employ, then rank the top five by their value to your organization's recruitment/training programs: Program Use Rank Explanation Internships	recruiting/training workers with little industr	ry experience.			Expla						
Program Use Rank Explanation Outreach to K-12	Indicate which of the following methods yo	ou currently employ	, then rank the	top five by	their value to y	our organization's	recruitment/training	programs:			
Outreach to K-12 Partership with local high schools Partership with local onmunity college -Yes Partership with local onmunity college -Ne Partership with local onmunities (e.g., Veterans) -Ne Partership with local American Job Centers -Ne Other (Specify here) -Ne Other (Specify here) -Ne Other (Specify here) -Ne ou have had difficulty obtaining and retaining the necessary skilled workforce; what steps could and should the U.S. government pursue to assist industry prevent that difficulty in the future? at key workforce programs are your organization undertaking to rebuild the semiconductor workforce in the U.S.? -Ne at does your organization offer to employees as part of workforce retention efforts? (e.g. salary/wage increases, bonuses, tuition reimbursement,. etc) at trainings or certifications does your organization cover for employees? -Ne at percentage of your current employees has received on-the-job training related to the skills identified as necessary for the industry and how often are these trainings conducted?	1 Internships			Use	Rar	ik 🛛		Explanation			
Partnershy with local biolacions Programme hypering is a second out of associations Partnershypering is a second out of associations Partnershypering is a second out of associations -Yes -No Partnershypering is a second out of associations -Yes -No Partnershypering is a second out of associations -No -No Partnershypering is a second out of associations -No -No Direct advertising -No -No Outrace to association associations -No -No Partnershypering with local American Job Centers - - Other (Specify here) - - Other (Specify here) - - Other (Specify here) - - out have had difficulty obtaining and retaining the necessary skilled workforce; what steps could and should the U.S. government pursue to assist industry prevent that difficulty in the future? at key workforce programs are your organization undertaking to rebuild the semiconductor workforce in the U.S.? - at does your organization offer to employees as part of workforce retention efforts? (e.g. salary/wage increases, bonuses, tuition reimbursement, etc) - at trainings or certifications does your organization cover for employees? - - <td>2 Outreach to K-12</td> <td></td> <td></td> <td></td> <td></td> <td></td> <td></td> <td></td> <td></td> <td></td>	2 Outreach to K-12										
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Partnership with semiconductor associations	4 Partnership with local community colleg	ge			- No						
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Direct devertising	7 Participation in career fairs										
Data control opcome control right to be formed by the rest of the rest	8 Direct advertising	Veteranc)									
Other (Specify here) Other (Specify here) outher (Specify here) entify the skills necessary for your industry that are currently least available: Image: Contract of the skills industry industry that are currently least available: ou have had difficulty obtaining and retaining the necessary skilled workforce; what steps could and should the U.S. government pursue to assist industry prevent that difficulty in the future? nat key workforce programs are your organization undertaking to rebuild the semiconductor workforce in the U.S.? nat key workforce programs are your organization offer to employees as part of workforce retention efforts? (e.g. salary/wage increases, bonuses, tuition reimbursement,etc) nat trainings or certifications does your organization cover for employees? nat percentage of your current employees has received on-the-job training related to the skills identified as necessary for the industry and how often are these trainings conducted? Comments	10 Partnership with local American Job Ce	enters									
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at trainings or certifications does your organization cover for employees?											
at percentage of your current employees has received on-the-job training related to the skills identified as necessary for the industry and how often are these trainings conducted?											
Comments	What trainings or certifications does your o	organization cover f	or employees?	•							
Comments	What trainings or certifications does your of what trainings or certifications does your of the work of the second	organization cover f es has received on-	or employees?	g related to	the skills identi	fied as necessary	for the industry and	how often are the	ese trainings con	ducted?	
	What trainings or certifications does your o	organization cover f	ior employees? the-job training	g related to	the skills identi	fied as necessary	for the industry and	how often are the	ese trainings con	ducted?	
DUCINECC CONFIDENTIAL Dev Continue 705(4) of the Defense Development and	Vhat trainings or certifications does your of Vhat percentage of your current employee Comments	organization cover f	for employees?	g related to	the skills identi	fied as necessary	for the industry and	how often are the	ese trainings con	ducted?	

Record \$ in Th	ousands, e.g. \$12,000.00 = sur	vey input of \$12					
Reporting Schedule:							
Income Statement (Select Line Items)	2017	2018	2019	2020	2021	2022 (Estimate)	Data Confirm
1 Net Sales (and other revenue)							2020 Net Sa
a. % of U.S. Sales							None
1.1. % of U.S. sales from U.S. locations							
1.2. % of U.S. sales from non U.S. locations							
b. % of Non-U.S. Sales							Dropdown:
2.1. % of non-U.S. sales from U.S. locations							- Calendar Year
2.2. % of non-U.S. sales from non-U.S. locations							- Fiscal Year
2 Cost of Goods Sold							
3 Total Operating Income (Loss)							
4 Earnings Before Interest and Taxes							
5 Net Income							
Balance Statement (Select Line Items)	2017	2018	2019	2020	2021	2022 (Estimate)	
1 Cash							1
2 Inventories							
3 Current Assets							
4 Total Assets							
5 Current Liabilities							1
6 Total Liabilities							1
7 Retained Earnings							1
8 Total Owner's Equity							
Human Capital Expenditure	2017	2018	2019	2020	2021	2022 (Estimate)	- 1
1 a. Total Salary and Wages (Including Benefits)							-2
b. Estimated costs associated with recruitment							- 4
c. Estimated costs associated with workforce training							- 5
o. Estimated oosts associated with workforce training		I	I		1	1	-6
	a sufficiency and 40 holes blacking	rafitable for the fea	coople future)	1			- /

Previous Page Section 10b: Research, Development	nt and Canital Expenditures										Next Page	ļ	
Besseret & Development (D&D)	Emenditure			2017	2018	2010	2020	2021	2022	2027	2032		
Research & Development (R&D)	Expenditure			2017	2018	2019	2020	2021	(Estimate)	(Expected)	(Expected)		
1 Total R&D Investment	1.1												
a. % of investment in R&D car	ried out in the U.S.												
Covernment Funded R&D				0047	0040	0040	0000	0004	2022	2027	2032		
Government-Funded Rab				2017	2018	2019	2020	2021	(Estimate)	(Expected)	(Expected)		
2 Total R&D funding received tro	m U.S. government sources			-									
b % of R&D funding from U.S.	State and Local Governments			-									
3 Total R&D funding received fro	m non-U.S. government sources												
a. Primary country and % of R	&D funding received			-									
A b. Secondary country and % of	R&D funding received												
c. Tertiary country and % of R8	D funding received												
Identify your organization's top anti	cipated R&D priorities over the new	t five years and pro	vide a brief description. Next, in	dicate the percent (%) of funding your	organization antic	cipates to receive	from government	both U.S. or non-	J.S.), and provide	the primary		
Country and State source of fundin													
R&D Priority		Description		Percent (%) of Funding		Primary	Source of Govern	ment Funding (as	applicable)			
				Anticipated fro	om Government	Co	untry	% of Funding	SI	late	% of Funding		
1													
2													
3													
4				_									
5									2022	2027	2032		
Capital Expenditure (CapEx)				2017	2018	2019	2020	2021	(Estimate)	(Expected)	(Expected)		
1 a. Total CapEx Investment													
c. % of investment outside of the	ne U.S.			-									
Does your organization expect	to use the investment tay credit inc	luded in Section 10	7 of the CHIPS Act of 2022 (al	80									
known as the FABS Act)?	to use the investment tax credit inc		of the of the O Act of 2022 (a)		Dropdown:	Exp	plain:						
					 Yes No 								
2 If Yes, estimate the expected to	otal value of the applicable investm	ent				Exp	plain:						
Deep your exercise tion evenest	to be imported by the comprete m	nimum toxinaluda	i so post of the Inflation										
Reduction Act of 2022?	to be impacted by the corporate in	minum tax include	as part of the milaton		Dropdown:	Exp	plain:						
					- Yes - No								
In the table below, identify your org	anization's anticipated top CapEx	priorities over the ne	ext five to ten years.										
For each CapEx priority, select the	option from the drop down menu t	hat best aligns with	your organization's investment	. If the option provid	ed do not represer	nt your organizatio	n's investment pri	ority, use the "Oth	er: Specify here:"	option to write in y	our response.		
Then, provide a description of the v	Japex investment priority. For example	ripie, il your organiz	adon is investing in equipment.	, describe the type o	r equipment that v	viii be acquired th	lough the investin	en.					
For the Product Category, select the providing the "Anticipated Total Co	he two product categories that will ist (\$)", indicate the overall cost of	be primarily affected he investment, incl	I by the investment and the res uding any governemnt or third p	pective primary tech party funding.	nology node. If yo	u need to report a	dditional product o	categories, use the	e comment section	at the end of the	page. When		
		1			1	1	1		1			Decadours	
CapEx In	vestment		Product Cotegory	imary Technology Node		Anticipated	Demont (9/)	of Coursemant	Primary Source	of Government Fu (as applicable)	Inding Anticipated	- Analog ICs	
B	1	Primary Facility	(select from dropdown)		Year	Total Cost (\$)	Percent (%) of Government Funding		Country			- Microcontroller and Microprocesso	
Priority	Description			Nanometer (nm)					Co	untry	State	- Memory ICs	
1												- Discretes	
Dropdown:												- Sensors & Actuato	ors
Pacility renovation Building of a new facility												- PCBs - Equipment/Toolin	p
3 - Expansion of existing faci	lity				-							- Intermediate/End	Product
- Equipment - Other: (Specify Here)												 Test and Design V Assembly and/or I 	ermcation Packaging
4													
5					-								
Have any of your investment project	erions increased due to unevaneted disruptions such as construction delays. Increase labor shortaneo/increased waves, etc. 2 If we indicate the two of delay. The never of bushet increase attributed to											Dropdown:	
the delay, the number of days dela	period increases or of inspected using units sources or sources or entry is a construction delys, increasing issues, indicated wayes, etc: In yes, indicate one type or dely, the period in object increase attrabuted to elayd, and provide an explanation.											- Other metric (spe	cify here)
Type o	Time of Datas												
(select from	im dropdown) (%) # of Days Delayed											Drandaura	
1												- No access to Gove	ernment Funding
2												- Licensing issues	
4												- Materials Shortag	e
6												- Construction dela	ys rol
7												State (specify He	,
1 Are any of your investment pla	ns currently on hold or pending unt	il government fundi	ng is available?										
Explain											•	Drande	1
c												- Yes	
2 Will investment plans receive f	oreign funding or incentives if U.S.	tunding is unavaila	ble?									- No	
Explain												N	- 1
												- Yes	
Comments												- No	
			BUSINESS CONFIDENTIAL .	Per Section 705(d)	of the Defense F	Production Act		-					•

Pre	vious Page	t Ventures and Dertherships								Next Page		
560	How many joi	nt ventures does your organization	on currently participate in?									
Identify your organization's current joint venture relationships, including public/private R&D partnerships. Explain the purpose of each joint venture (e.g. patent licensing, co-production, product integration, after-market support, etc.), as applicable.												Il resources ment contracts
	Partner	Organization/Entity Name	Country	Controlling Shareholder	Year Initiated	Primary Purpose of (select from dr	f Relationship opdown)		Explain		 Access to Intellect Access to supplie Broaden custom 	tual Property rs or reduced lead times er base
	2										 Creation of new - Develop new car 	echnologies or product improvements abilities
	3										- Improved access	to foreign markets (required)
~	5				 Improved access Improved access 	to foreign markets (voluntary) to U.S. markets						
	6					- Other objective/	purpose (Explain)					
	8										- R&D access/coor	dination
	10										- Reduce Costs	
	11										- Shared/improved	technology or skills
	13										 Tax-related Vertical integrati 	n
	14											
	Has your orga	nization had any actions blocked	(or failed as a result of lack of governmer	t approval) or mandated by	a governm	ent entity? Such actior	ns might include	mergers, acquisitions,	ioint ventures.			
	partnerships,	sales agreements, licensing agre	ements, etc.	,	5	,	5	5,1,,	, , , , , , , , , , , , , , , , , , ,			
	If yes, identify	the action(s) and government(s)	involved.								Dropdown: - Yes	
		Actions	Government Involved				Ex	plain			- No	
	1											
	2											
3												
	4											
	5											
	Has your orga	nization received solicitations or	requests for partnership from entities that	are known/suspected of bein	g state ow	ned or affiliated with fo	reign governmen	t?				
	If yes, identify	each entity and the foreign gove	nrment, then provide an explanation.	1								
		Entity Name	Foreign Government				Ex	plain				
В	1											
	2											
	3											
	4											
	5											
	Has your orga	inization felt coerced to share tec	hnology with a JV partner or government?									
	If yes, provide	the following information for eac	h instance your organization felt coreced t	o share technology.								
		Entity Name	Type of Technology	Description		Did the transfer occur?	Method	d of Transfer	Country (if applicable)	Estimated Value (USD) of the transferred technology		
	2						7					
	2					Dropdown: - Yes						
	3					- No						
	5						_					
Does your organization currently participate in any semiconductor industry consortia? If yes, please provide an explanation.												
C Explain										1	Dropdown:	
Does your organization currently participate in any Cooperatve Research or Production Agreements? If yes, please provide an explanation.										- tes - No		
	Explain										Dropdown:	
Co	mments										- Yes - No	
			BUSINES	S CONFIDENTIAL - Per Sec	ction 705(d	d) of the Defense Proc	duction Act					

Intervise state-controlled? If yes, identify the most recent entities of such transfers, the beneficiary county, the primary method of transfer, the type of IP, and provide an explanation. Entity Name Beneficiary Country Primary Method of Transfer Type of IP Explain 1 2	
Entity Name Beenficiary Country Primary Method of Transfer Type of IP Explain 1	Dropdown:
Image: Control of the problem of t	- Yes - No
A 2 Dropdom: Dropdom: 4 - - Dropdom: - 5 - - Dropdom: - 6 - - Dropdom: - 7 - - Dropdom: - 8 - - Participation in scientific/technical conferences - 9 - - Participation in scientific/technical conferences - 10 - - Participation in scientific/technical conferences - 10 - - Non-Disclosure Agreements (NDAs) - - 10 - - - Non-Disclosure Agreements (NDAs) - - 10 - - - Non-Disclosure Agreements (NDAs) - - - - - - Non-Disclosure Agreements (NDAs) - <t< td=""><td></td></t<>	
A B Dropdown: 3	
4 - Leensing intellectual property - Design 5 - Consider the secrets of confidential conferences - Manufacturies 7 - Confidential conferences - Soft 8 - On-Disclosure Agreements (NDAs) - On-Disclosure Agreements (NDAs) 9 - On-Disclosure Agreements (NDAs) - On-Disclosure Agreements (NDAs) 10 - Other (Specify Here) - Other (Specify Here) 10 - Other (Specify Here) - Other (Specify Here) 10 - Other (Specify Here) - Other (Specify Here) 10 - Other (Specify Here) - Other (Specify Here) 10 - Other (Specify Here) - Other (Specify Here) 10 - Other (Specify Here) - Other (Specify Here) 10 - Other (Specify Here) - Other (Specify Here) 10 - Other (Specify Here) - Other (Specify Here) 10 - Other (Specify Here) - Other (Specify Here) 10 - Other (Specify Here) - Other (Specify Here) 10 - Other (Specify Here) - Other (Specify Here) 10 - Other (Specify Here) - Other (Specify Here) 10 - Other (Specify Here)	
5	
6 - Participation in scientific/technical conferences 7 - Information provided to optential investors 8 - Non-Disclosure Agreements (NDAs) 9 - Other (Specify Here) 10 - Other (Specify Here) Has your organization experienced any unauthorized transfers of its microelectronics-related design and manufacturing intellectual property, including trade secrets or confidential business information, cocurred from 2017 to present? Indicate the methods by which unauthorized transfers of your organization's microelectronics-related design and manufacturing intellectual property, including trade secrets or confidential business information, occurred from 2017 to present, the suspected location of the perpetrator(s), the type of IP, trade secrets or confidential business information, occurred from 2017 to present, the suspected location of the perpetrator(s), the type of IP, trade secrets or confidential business information mature and the secrets or confidential business information in the was transferred, and explain. Very brief infusions - Orgen IP/ TradeSecrets/ Confidential Business Information Phanting staff in your organization - Design Physical break-ins at organization facilities - Design Business partners - Design Business partners - Design Business partners - Design Business partners - Design Burenenployees - Design	
7	
8 - Non-Disclosure & greements (NDAs) 9 - Other (Specify Here) 10 - Other (Specify Here) Has your organization experienced any unauthorized transfers of its microelectronics-related design and manufacturing intellectual property, including trade secrets or confidential business information, from 2017 to present? Indicate the methods by which unauthorized transfers of your organization's microelectronics-related design and manufacturing intellectual property, including trade secrets or confidential business information, occurred from 2017 to present, the suspected location of the perpetrator(s), the type of IP, trade secrets or confidential business information hat was transferred, and explain. Method Suspected Country Suspected Perpetrator if Known Type of IP/ TradeSecrets/ Confidential Business Information Explain Planting staff in your organization - - - - Planting staff in your organization facilities - - - - B Dumpster diving - <t< td=""><td></td></t<>	
9 - Other (Specify Here) 10 - Other (Specify Here) Has your organization experienced any unauthorized transfers of its microelectronics-related design and manufacturing intellectual property, including trade secrets or confidential business information, from 2017 to present? Indicate the methods by which unauthorized transfers of your organization's microelectronics-related design and manufacturing intellectual property, including trade secrets or confidential business information, occurred from 2017 to present, the suspected location of the perpetrator(s), the type of IP, trade secrets or confidential business information that was transferred, and explain. Wethod Suspected Country Suspected Perpetrator if Known Type of IP/ TradeSecrets/ Confidential Business Information Explain Planting staff in your organization Propdown: - - - B Dumpster diving - - - - - Current employees - - - - - - External IT system contractors -	
Has your organization experienced any unauthorized transfers of its microelectronics-related design and manufacturing intellectual property, including trade secrets or confidential business information, form 2017 to present? Indicate the methods by which unauthorized transfers of your organization's microelectronics-related design and manufacturing intellectual property, including trade secrets or confidential business information, occurred from 2017 to present? Indicate the methods by which unauthorized transfers of your organization's microelectronics-related design and manufacturing intellectual property, including trade secrets or confidential business information, accurred from 2017 to present? Method Suspected Country Suspected Perpetrator if Known Type of IP/ TradeSecrets/ Confidential Business Information Explain Cybersecurity intrusions Method Suspected Country Suspected Perpetrator if Known Type of IP/ TradeSecrets/ Confidential Business Information Explain Planting staff in your organization Propdown: -	
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Indicate the methods by which unauthorized transfers of your organization's microelectronics-related design and manufacturing intellectual property, including trade secrets or confidential business information, occurred from 2017 Method Suspected Country Suspected Perpetrator if Known Type of IP/ TradeSecrets/ Confidential Business information Explain Cybersecurity intrusions Image: Cybersecurity intrusions	
Method Suspected Country Suspected Perpetrator if Known Type of IP/ TradeSecrets/ Confidential Business Information Explain Cybersecurity intrusions Explain Explain Explain Explain <	Dropdown: - Yes - No
Cybersecurity intrusions Image: Cybersecurity intrusicybersecurity intrusins Image: Cybersecurity intrusi	
Planting staff in your organization Planting staff in your organization Image: Constraint of the staff in your organization Physical break-ins at organization facilities Image: Constraint of the staff in your organization Image: Constraint of the	
Physical break-ins at organization facilities Omeganization facilities Business partners Image: Constraint of the second	
B business partners Composition	
B Dumpster diving -Both Current employees (other than persons performing R&D within your organization) -Both -Both Former employees -Both -Both External IT system contractors -Both -Both Persons performing R&D within your organization -Both -Both Organization campus Wi-Fi network interceptions -Both -Both Divisionary buy within is inductive required computed comparison -Both -Both	
Current employees (other man persons performing R&D within your organization) Image: Current employees Former employees Image: Current employees External IT system contractors Image: Current employees Persons performing R&D within your organization Image: Current employees Organization campus Wi-Fi network interceptions Image: Current employees Divelopment hundrich inductor computed temperature Image: Current employees	
Former employees Image: Constractors External IT system contractors Image: Constractors Persons performing R&D within your organization Image: Constractors Organization campus Wi-Fi network interceptions Image: Constractors Displement build in inductive camputation protection Image: Constractors	
Persons performing R&D within your organization	
Organization campus Wi-Fi network interceptions	
Diselectre by attride inductor explorate	
Disclosure by outside industry analysis/expens	
Disclosure by your bankers/financiers	
Disclosure by contractors and suppliers	
Violation of Non-Disclosure Agreements (NDAs)	
Insertion of vulnerabilities in the supply chain	
Compromised managed service provider	
Phishing/spear-phishing	
Other (Specify Here)	
Comments	

Pre Sec	<u>vious Page</u> ction 12: Competitive Factors					Next Page
	Estimate the current percentage of cost of sales	by process step, as well a	as the breakout of the per	centage of cost of sales ca	rried out or s	ourced (a) in the U.S. and (b) outside of the U.S.
	Process Step	Percent (%) of Cost of Sales	Percent (%) Carried out or sourced in U.S.	Percent (%) Carried out or sourced outside U.S.		Explain
	1 Direct Labor					
	a Design Labor					
	b Front-End Manufacturing Labor					
	c Back-End Manufacturing Labor					
_	2 Core IP					
^	3 Exprisation as a Service (Foundry Services)					
	4 Material Inputs					
	5 Processed Inputs					
	6 Energy					
	7 Weter					
	7 Water					
	9 Assembly and/or Packaging					
	10 Transportation					
	11 Other					
	For each of the following factors, indicate whether next most important, etc.) when deciding on a loca	r locating the factor inside ation to invest on the exp	the U.S. or outside the U ansion or construction of f	.S. provides the greater co acilities, and explain.	mpetitive ad	vantage. Next, rank your organization's top five factors (1 being the most important; 2 being the
	Factor		Location with Greatest Advantage	Country with Greatest Advantage	Rank	Explain
	Labor Cost					
	Labor Availability					
	Labor Quality		Dropdown:			
	Material Cost		- U.S.			
	Material Availability		- Non-U.S			
	Material Quality		- Neither			
	Equipment Cost					
	Equipment Availability					
	R&D Cost					
в	R&D Quality					
	Energy Reliability					
	Environmental Compliance Cost					
	Export Control Compliance Cost					
	Export Control Policies					
	Energy Cost					
	Renewable Energy Accessibility					
	Construction Time					
	Construction Cost					
	Proximity to Customers					
	Tax Costs					
	Government Incentives					
	Collaboration Benefits					
	Ability to Protect IP	(
	Other	(specify here)				
	Ullel	(specity nere)	1			
	Comments					
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Pr	evio	ous Page	Next Page						
Se	ctio	on 13: Long Term Development and Investment							
	W	hat factors do you consider when investing on the e	xpansion or construction of facilities? Please list the decision making factors by importance.						
		Desiding Easter	Evaluation						
			Explanation						
A	2			Dropdown:					
	3			- Core IP - Electronic Design Automation (EDA)					
	4			- Design					
⊢	5			- Test and Verification					
	W	hich value chain segments are most in need of gove	ernment incentives and/or financial intervention? (List up to the 3 by order of importance).	- Assembly and/or Packaging					
	-	Value Chain Segment	Ender the	- Equipment and Tooling					
		(select from dropdown)	Explanation	- Materials and/or Components					
	1			- R&D					
	2 Distribution/Warehousing								
	3			- Other					
		Are there any regulations proventing your organize	tion from constructing, expanding or modernizing any feelilities in the LLC 2 If use, provide an explanation						
	Ľ	Are there any regulations preventing your organiza	autor nom constructing, expanding or modernizing any facilities in the 0.5.2 in yes, provide an explanation.	A					
				Dropdown:					
				- Yes - No					
	2	What can the U.S. government do to promote high	er investment of microelectronics manufacturing in the United States?						
	3	What can help your organization's coordination wit	h local economic development organizations to help facilitate investment?						
	A How can the United States government help facilitate the long-term competitiveness of your organization?								
	I how can the United States government help facilitate the long-term competitiveness of your organization?								
В									
	5	What other economic clusters should the United S	tates Government invest in to help strengthen the semiconductor industry? For example, AI, etc. How could these investments benefit						
	-	your company?							
	6	How could the United States Government stimulat	e R&D partnerships within the semiconductor fields and related sectors such as metals, materials, etc at research universities, etc to						
	Ľ	help with R&D?							
	7 What are the most important emerging technologies that your organization is currently exploring or developing?								
	8 What are the most important emerging technologies for the microelectronics industry as a whole?								
	Trite de la most importain enleging technologies foi die mitobaleuromes industry as a mitore :								
		L							
	9	What are the main obstacles to introducing emerg	ing technologies into broad-scale manufacturing? Are those obstacles larger or smaller in the United States? How and why?						
	1								
		Comments							
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Previous Page

Section 14: Challenges

Identify the issues that have impacted your organization between 2017 to present and the issues that you anticipate will impact your organization between 2023 and 2027. Then, rank your organization's top five issues for both time frames (1 being the most important issue; 2 being the next most important issue, etc.) and explain the affirmative issues where examples and narrative will aid the U.S. Government's understanding of your concerns. Then, provide any suggestions for ways the U.S. Government can help mitigate the issue, if applicable. Explanations and suggested solutions are helpful but not required.

	Time of locus		2017 t	o 2022		2023 to 2027		European at leave	
	Type of Issue	-Yes	/No-	Rank	-Ye	es/No-	Rank	Explanation of Issue	Suggested USG Solution/Mitigation
Agin	ng equipment, facilities, or infrastructure		~ \			\sim			
Agir	ng workforce								
Corr	npetition - domestic		Dror	odown:		Dron	down		
Corr	npetition - foreign		- Yes			- Yes			
Cou	nterfeit parts		- No			- No			
Cyb	er security								
Envi	ironmental regulations/remediation								
Exp	ort controls/ITAR & EAR								
Fina	ncing/credit availability								
Gov	ernment acquisition process								
Gov	ernment purchasing volatility								
Gov	ernment regulatory burden								
A Hea	Ithcare								
Indu	strial espionage - domestic								
Indu	strial espionage - foreign								
Inpu	t availability (e.g. materials)								
Inpu	t quality								
Intel	lectual property/patent infringement								
Labo	or availability/costs								
Lack	k of infrastructure								
Lack	k of public R&D partnerships (e.g. universities)								
Natu	ural disasters (including disease/quarantine)								
Obs	olescence								
Pen	sion costs								
Prov	kimity to customers								
Prox	kimity to suppliers								
Qua	lifications/certifications								
R&E) costs								
Red	uction in USG demand								
Taxe	es								
Trac	de disputes								
Wor	ker/skills retention								
Othe	er (specify here)								
Othe	er (specify here)				-				
Othe	er (specity nere)								
	Comments								
				BUSINESS	CON	FIDEN	TIAL - Per	Section 705(d) of the Defense Production Act	

Previous Page	Next Page							
Section 15: Certification								
The undersigned certifies that the information herein supplied in response to this questionnaire is complete and correct to the best of his/her knowledge. It is a criminal offense to willfully make a false statement or representation to any department or agency of the United States Government as to any matter within its jurisdiction (18 U.S.C. 1001 (1984 & SUPP. 1197))								
Once this survey is complete, first save it to your computer, and then submit the document via [instructions TBA].								
Organization Name								
Organization's Internet Address								
Name of Authorizing Official								
Title of Authorizing Official								
E-mail Address								
Phone Number and Extension								
Date Certified								
In the box below, provide any additional comments or any other information you wish to include regarding this survey assessment.								
How many hours did it take to complete this survey?								
BUSINESS CONFIDENTIAL - Per Section 705(d) of the Defense Production Act								

Definitions		
General Purpose Analog	General Purpose Analog is sub-adviced into specific functional subcategories of Angines/Comparison (Signal Conditioning), signal Conversion, Interface, and Power Management/Cs. These subcategories are defined in terms of functionality instead of a specific circuit type. A device should be classified into one of the following subcategories depending on its primary or dominant function, regardless of the mix of circuitry used in the device.	
Interface	General Purpose Analog ICs whose primary or dominant function is to modify or shape the signal in order to ensure signal integrity for transmission over a distance through a physical medium such as a wire, cable, waveguide, or tracks within a printed circuit board. These include devices which shape the signal for transmission over the medium or which reconstructs the received signal after transmission to recover the intended signal integrity. A device may be classified into this category if at least one of the following is true; the signal at the input of the device is analog in nature, or the signal at the output of the device is analog in nature. An analog signal is defined as a signal which is continuously varying in voltage or current over time, and is not a digital signal with discrete levels.	
Power Management	General Purpose Analog ICs whose primary or dominant function is to convert, control or distribute DC power. This category includes devices which convert a source voltage into another voltage which can be used for powering other integrated circuits and which include a management capability to control the output voltage. AC to DC power conversion should be included in this category. General purpose LED drivers are classified into the appropriate Regulator category. Only products which are integrated circuits should be classified in this Power Management category. Discrete devices such as transformers, bridges and inductors used for power conversion should be classified into one of Discrete categories A-E. Power management ICs designed for use in a specific end application should be classified into the appropriate Application Specific Analog category of JB-JF.	
Signal Conversion	General Purpose Analog ICs whose primary or dominant function is to convert the signal from one form to another for further processing by other ICs including digital ICs such as a microprocessor or FPGA. The signal before or after conversion should be analog. These include general purpose devices whose primary function is Analog-to-Digital conversion, Digital-to-Analog conversion, and Voltage-to-Frequency conversion. Discrete sample-and-hold circuits are part of this category. However, this function is generally integrated into the signal conversion circuit. Analog switches and multiplexers which are often used with the above converters are included in this category.	
Amplifiers/Comparators	General Purpose Analog ICs whose primary or dominant function is to condition or modify the incoming Analog signal to enhance it for further processing such as signal conversion or interfacing. This category includes devices which provide functions such as signal filtering, signal amplification, level shifting, buffering or comparison.Current sense amplifiers and trans-impedance amplifiers are included in this category	
Application Specific Analog	Among all analog circuits according to the general definition (seethe first paragraph of 3.4.1. Analog), this category includes those, which are uniquely designed for a specific application and fall in one of the following categories from JB to JF. These circuits may be customer specific or catalog products for multiple customers sharing the same application. They may be based on any technology and on any methodology of design.	
Consumer	Application Specific Analog ICs designed specifically for and used in consumer applications / end equipment. Consumer end equipment is defined as those which are intended for personal or home use, is usable by all demographics, and are generally used for entertainment, capturing/storing of images and audio/video for personal consumption, and for home convenience. They are generally designed for use in the home but are increasingly becoming more and more portable. Included in this category are Digital TVs (DTV), Digital Still Cameras, MP3 players, DVD players, Set Top Boxes (STB), Game Consoles, Hi-Fi Audio/Video products, Home Entertainment Systems and White Goods.	
Computer	Application Specific Analog ICs designed for and used in Computing and Computer applications including computer peripherals. ICs in this category are reported into the following subcategories based on the function for which they are designed.	
Communications	Application Specific Analog ICs designed for and used in non-military voice and data communications end equipment and infrastructure. ICs under this category shall be classified into one of the following subcategories depending on the application for which they are designed.	
Automotive	Application Specific Analog ICs designed for and used in Automotive end equipment.	
Industrial & Others	Application Specific Analog ICs designed for and used in Industrial end equipment as defined below, or other applications not specified in JB-JE above. ICs containing semiconductor sensor elements together with analog circuitry shall be classified into the appropriate category in H99- Sensors, irrespective of the analog content and functions of thecircuit.	
Diodes	General-purpose signal and switching diodes (rated less than 0.5 AMP), zener diodes, transient protection diodes and RF & microwave diodes.	
Small Signal and Switching Transistors	Transistors with a power dissipation of less than 1W (the power dissipation represents, for lead mounted types, the rating at 25 degrees C free air or ambient temperature and, for chassis mounted types, the rating at 25 degrees C case temperature). This category includes all RF and microwave small signal transistors, dual transistors, field effect transistors and all generalpurpose bipolar small signal transistors.	
Power Transistors	Transistors with a power dissipation of 1W or more (the power dissipation represents,for lead mounted types, the rating at 25 degrees C free air or ambient temperature; and, for chassis mounted types, the rating at 25 degrees C case temperature). This category includes RF and microwave power transistors, bipolar general purpose power transistors, field effect general purpose power transistors, insulated gate bipolar transistors (IGBT). Darlington power transistors, multiple chip devices which behave as a single chip device except for higher current and power rating, and modules assembled from these transistors.	
Rectifiers	Includes all discrete rectifiers (rated at 0.5 AMPS average or greater) and assemblies/modules composed thereof.	
Thyristors	Includes all unidirectional and bi-directional thyristors and assemblies/modules composed primarily thereof.	
All Other Discrete	Includes varactor tuning diodes, selenium rectifiers and other polycrystalline devices, and any other discrete semiconductor device not specifically listed above.	
Digital Bipolar	Includes all digital logic and memory product that is made with bipolar integrated circuitry technology (TTL, ECL, DTL, IIL, RTL, etc.). Included are general purpose logic (including CML, ECL, EFL, TTL Schottky, Advance Schottky, Standard TTL and other bipolar logic devices), Gate Array, Standard Cell, bipolar memory and all other bipolar logic circuits (such as FPL, MPU, MCU, micro peripherals, etc.).	
MOS General Purpose Logic	Devices in this classification are standard commodity catalog products, usually simple gates, flip-flop circuits and registers. These are used in a wide range of equipment for applications in various market segments. Excluded are catalog products of any programmable device or any Special Purpose Application Specific (ASIC) device.	
MOS Gate Arrays	Devices in this classification are logic circuits consisting of fixed and regular arrangement of transistor cells forming a matrix of logic gates of various standard densities. These devices are Customer Specific Integrated Circuits (CSIC) whose design is controlled by customer and are usually proprietary to a specific customer. The manufacturer provides a standard library of logic gates and provides the necessary design tools needed to generate a final metallization interconnect mask set	
MOS Standard Cells	Standard Cells are circuits consisting of a user-specified arrangement of predefined and fixed sub-circuits of any function (analog, logic or memory, etc.).	
MOS Display Drivers	Devices specifically designed to control and drive flat panel displays such as LCD (liquid crystal display), PDP (plasma display panels), etc	

MOS Touch Screen Controllers	Controller devices which accompany touch screen displays and are capable of determining the location of single or multi-touch gestures, styli and gloves, using capacitive, resistive or other sensing technologies. These devices are used for interfacing with user's touches on screen displays, i.e. the technology typically prevalent in gaming consoles, media tablets, smartphones, notebook PCs, PDAs, satellite navigation devices, digital still cameras (DSC), etc. Touch screen controllers designed based on any technology, such as firmware, MCU, or logic circuits, should be reported into this category L4, even though they may have been reported into other categories, such as P5 General MCU, L7a Wireless Communication, Cellular Phone (under LA MOS Special Purpose Logic), etc.
Consumer	MOS logic ICs designed specifically for use in consumer equipment such as entertainment, radio, TV, HDTV, Set Top Box, VCR, DVD Player, personal or home appliance, camera, game, etc.
Computer & Peripherals	MOS ICs designed specifically for use in computer equipment or computer peripherals. Application specific ICs designed specifically for use in (a) computer systems, (b) rotating computer magnetic and optical disk storage or tape mass storage media (c) other computer periphery applications (e.g., such as printers, scanners, monitors, keyboards, mice, etc.) are reported in this category.
Communication	MOS ICs designed specifically for voice or data communications applications. These applications include telecommunication network products such as switching equipment, multiplexing equipment, repeaters and line-conditioning equipment; customer premise equipment such as Centrex, key systems, PBX; personal communications products (telephone sets including wireless/cellular), modems, facsimile and answering machines, and tablets. ICs in this category are reported into the following subcategories based on the function for which they are designed.
Automotive	ICs designed specifically for use in auto entertainment, navigation, driver information, engine controls and all other automotive applications.
MOS Special Purpose Logic	The devices in this category are either (i) Application Specific Standard Products (ASSP) designed by semiconductor manufacturer or (ii) Customer Specific Integrated Circuits (CSIC) designed by the customer, all of which are specifically designed for one of the application segments listed below. In addition to logic circuitry, these ICs may include other functions such as analog, micro or memory, and all or part of the circuitry of the products may be based on multiple cores, Gate Array technology, Standard Cell technology, FPL technology, or any combination thereof. Touch Screen Controller devices shall be reported to L4 MOS Touch Screen Controller, including ASSP and CSIC, and those based on any technology.
Multipurpose & Other	ICs designed for multiple applications or for industrial, instrument, military or other applications
MOS DRAM	Dynamic Random Access Memory devices in which bit words (1 bit or longer word length) can be written, stored and read randomly in any desired sequence. The memory information is volatile and is lost when the power supply voltage is removed
Other Memory	Electrically Erasable PROMs (except Flash Memory) and all other MOS Memory devices not defined in M1, M2, M8 and M7. Specifically includes serial FIFOs and LIFOs as well as EAROM (Electrically Alterable ROM) and NOVRAM (Non Volatile RAM). Devices in this category are reported into the following subcategories based on the function for which they are designed
MOS SRAM	Static Random Access Memory devices are similar to DRAMs except that SRAMs are based on a minimum four transistor memory cell which is configured into a flip-flop circuit. Some SRAMs do not need to have the memory cells refreshed since the bit information is represented by a steady state current in one side of the flip-flop and no current in the other, however "Pseudo SRAMs" have a built-in oscillator which enables self refreshment. Pseudo SRAMs hence behave as a DRAM but are included in M2 for reporting purposes.
MOS Mask PROM & EPROM	Mask Programmable Read Only Memory are non-volatile circuits which have single transistor memory cells that are locked on or off in a pre- determined pattern by means of a masking procedure during the fabrication process. <u>EPROM</u> - Electrically Programmable Read Only Memory devices are non-volatile circuits similar to Mask PROMs except that the memory data pattern is programmed by electrical means rather than a fixed mask. Included are OTP, One Time Programmable devices, from which the programmed memory data pattern is not erasable. EPROMs other than OTPs have a window in the package whereby theprogrammed memory data pattern may be erased using ultra-violet light and then electrically reprogrammed.
NOR Flash Memory	A type of EEPROM (Electrically Erasable and Programmable Read Only Memory) in which the memory data is electrically erased by large arrays of bits rather than by fractions such as bit by bit, classified in the following subcategories: 2M Bit & less - NOR-Type Flash Memory containing up to and including 2 megabits of memory. 4M Bit & less (>2M) – NOR-Type Flash Memory containing more than 2 megabits and up to and including 4 megabits of memory. 8M Bit & less (>4M) – NOR-Type Flash Memory containing more than 4 megabits and up to and including 8 megabits of memory. 16 M Bit & less (>4M) – NOR-Type Flash Memory containing more than 8 megabits and up to and including 16 megabits of memory. 32 M Bit & less (>6M) – NOR-Type Flash Memory containing more than 16 megabits and up to and including 32 megabits of memory. 44 Bit & less (>16M) – NOR-Type Flash Memory containing more than 16 megabits and up to and including 32 megabits of memory. 45 M Bit & less (>23M) – NOR-Type Flash Memory containing more than 32 megabits and up to and including 64 megabits of memory. 48 M Bit & less (>64M) – NOR-Type Flash Memory containing more than 64 megabits and up to and including 128 megabits of memory. 49 M Bit & less (>64M) – NOR-Type Flash Memory containing more than 64 megabits and up to and including 128 megabits of memory. 40 Bit & less (>64M) – NOR-Type Flash Memory containing more than 128 megabits and up to and including 128 megabits of memory.
NAND Flash Memory	bits rather than by fractions such as bit by bit, classified in the following subcategories: 512 M Bit & less – NAND-Type Flash Memory containing up to and including 512 megabits of memory 1 G Bit & less (>512M) – NAND-Type Flash Memory containing more than 512 megabits and up to and including 1 gigabits of memory 2 G Bit & less (>1G) – NAND-Type Flash Memory containing more than 1 gigabits and up to and including 2 gigabits of memory 4 G Bit & less (>2G) – NAND-Type Flash Memory containing more than 2 gigabits and up to and including 4 gigabits of memory 8 G Bit & less (>2G) – NAND-Type Flash Memory containing more than 4 gigabits and up to and including 8 gigabits of memory 16 G Bit & less (>4G) – NAND-Type Flash Memory containing more than 8 gigabits and up to and including 16 gigabits of memory 16 G Bit & less (>6G) – NAND-Type Flash Memory containing more than 8 gigabits and up to and including 16 gigabits of memory 32 G Bit & less (>16G) – NAND-Type Flash Memory containing more than 8 gigabits and up to and including 32 gigabits of memory 32 G Bit & less (>32G) – NAND-Type Flash Memory containing more than 32 gigabits and up to and including 64 gigabits of memory Greater than 64 G Bit – NAND-Type Flash Memory containing more than 64 gigabits of memory

MOS MPU	The MPU category includes ICs which execute external instructions and perform system control functions as programmed via software with the assembly language instructions retrieved from external memory with data read from and written to external RAM devices to perform system functions. This set up allows the MPU to receive a variety of input commands, manipulate data, direct storage of data and initiate application commands to the outside world. The most common usage is in Multi-Task Computer systems such as PCs. The ICs in this category include Complex Instruction Set Computers (CISC) and Reduced Instruction Set Computers (RISC). The architecture is optimized for general-purpose data processing and includes an instruction decoder, arithmetic logic unit, registers and additional logic to support operation per an assembly language. There is no addressable ROM or RAM within the device, but may include dedicated registers, ROM for micro code and/or on-chip cache.
MOS MCU	These ICs are stand-alone devices, which perform dedicated or embedded computer functions within an overall electronic system without the need of other support circuits. Like microprocessors these include an instruction decoder, arithmetic logic unit, registers and support logic (UARTs, Counter Timers, Comparators, etc.). Unlike microprocessors, MCUs contain some form of ROM, EPROM or Flash Memory, which are programmed to store customer-supplied instructions. The MCU also incorporates read-write memory (RAM) for temporary storage. The embedded instructions cause the MCU to perform pre-determined tasks such as controlling functions in TV, VCR, microwave ovens and automobile engines. In more complex applications the device may need peripheral logic devices or external memory but for simple tasks the device is self-sufficient.
General Purpose MCU	All MCUs including those designed for specific applications and general purposes, other than Smart Cards (i.e. IC cards).
Automotive MCU	MCUs designed for application in automotive entertainment, navigation, driver information, engine controls and all other automotive applications. Automotive MCUs are classified into (I) P5x Infotainment (Information & Entertainment Systems) and (II) P5y Other Automotive
Smart Card MCU	MCUs specifically designed for use in Smart Cards (i.e. IC cards). Total of the Smart Card MCU is classified into the following three (3) sets of subcategories, i.e. (i) by Data Bus, (ii) by Application, and (iii) by Interface.
MOS DSP	Unlike other processors, which usually are embedded in some digital Microcomputer system, DSPs are most commonly used in analog systems to process real time data. Such systems require conversion of the analog signals to digital and hence the systems need A-D and DA converters, which may be integrated on the chip of the DSP used in such systems. The DSPs use parallel multipliers with separate program and data areas (Harvard type architecture), which provide very high-speed performance required in "Sum-of-Product" operations.
Displays	Single or Multiple Digit character displays are reported as complete assemblies.
Light Sensors	Monolithic and assembled modules that detect presence of light and change it into electrical voltages or currents. Such devices include discrete and combo sensors, such as Ambient Light Sensors (ALS), Proximity Sensors (including IR LED Emitter in a same package), Color Sensors (RGB), Ultraviolet Sensors, Heart Rate Sensors, etc.
Lamps	Discrete solid-state light source (visible only) of any size, shape, color and light intensity.
Opto Couplers & Isolators	The device consisting of optical emitting die (mostly infrared) and a silicon detector which is optically coupled with the emitter. The device may be a phototransistor, opto triac or opto IC, integrated into a single package. Coupling devices are designed for signal transmission between two electrically separated circuits. Isolaters perform galvanic and electrical isolation between input and output circuitry by using isolating material. The change of the output signal is driven by the change of the input signal. These devices are primarily used to protect the microcontroller from interferences from the power side of the circuitry, in such applications as power supplies, line receivers, computer interfaces, etc.
Optical Switches	Transmissive switches include an emitting die (mostly infrared) and a detector located on the opposite side of the optical axes in a single package, and the light path is broken or modified by an external physical object. Transmissive switches are used for small distances and narrow objects. Reflective switches have the emitter positioned next to the detector, and the signal transmission goes by reflection of a dedicated media. Reflective switches are used for a wide range of distances and objects of different shapes. Interrupters convert mechanical movements into electrical signals. With these devices, the change of the output signal is made by interrupt or reflection of an infrared beam with a media.
CCD & Other Image Sensors	CCD and all Image Sensors not included under F5b below.
CMOS Image Sensors	Image sensors in CMOS technology including ancillary analog and/or digital circuit functions on the same chip.
Other Optoelectronics	All other optoelectronics devices not specifically listed above, including fiber optic components and solar cells.
Infrared	Infrared emitters and all detectors. Includes both discrete devices and assembled modules.
Laser Pickup	Devices generating coherent radiation whose wavelength is generally 0.8um and less, mainly used for optical disk drives.
Laser Transmitter	Devices generating coherent radiation whose wavelength is generally greater than 0.8um, mainly used for optical communications.
Temperature & Other Sensors	All devices for measurement of temperature in gases, liquids or solids, and all other non-optical sensors not included in H2, H3, H4 and H6.
Pressure Sensors	All devices for direct measurement of pressure.
Acceleration & Yaw Rate Sensors	All devices for direct measurement of acceleration and yaw rate or spin rate.
Magnetic Field Sensors	All devices for measuring any kind of magnetic field
Actuators	Devices with the primary purpose to translate electrical signals into physical actions. These devices may also contain complex digital and/or analog
Applied Research	A systematic study to gain knowledge or understanding necessary to determine the means by which a recognized and specific need may be met. This activity includes work leading to the production of useful materials, devices, and systems or methods, including design, development, and improvement of prototypes and new processes.
Authorizing Official	An executive officer of the organization or business unit or another individual who has the authority to execute this survey on behalf of the organization.
Bare Printed Circuit Board	A completed, tested circuit board ready to be populated with components to create a working system.
Basic Research	A systematic, scientific study directed toward greater knowledge or understanding of the fundamental aspects of phenomena and of observable facts.
Capability	The ability to perform standardized design and/or manufacturing steps for producing integrated circuit products within an organization's own facilities and its own employees with little or no outsourcing.
Capital Expenditures	Investments made by an organization in buildings, equipment, property, and systems where the expense is depreciated. This does not include expenditures for consumable materials, other operating expenses, and salaries associated with normal business operations.
Commercial and Government Entity (CAGE) Code	A unique identifier for companies doing or seeking to do business with the U.S. Federal Government. The code supports mechanized government systems and provides a standardized method of identifying a given facility at a specific location. Find CAGE codes at https://cage.dia.mii/search/ .
Customer	An entity to which an organization directly delivers the product or service that the facility produces. A customer may be another organization or another facility owned by the same parent organization. The customer may be the end user for the item but often will be an intermediate link in the supply chain, adding additional value before transferring the item to yet another customer.

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Cybersecurity	The body of technologies, processes, and practices designed to protect networks, computers, programs, and data from attack, damage, or unauthorized access.		
Data Universal Numbering System (DUNS)	A nine-digit numbering system that uniquely identifies an individual business. Find DUNS codes at http://fedgov.dnb.com/webform.		
Development	The design, simulation, and testing of a prototype, including experimental software or hardware systems, to validate technological feasibility or concept of operation in order to reduce technological risk, or provide test systems prior to production approval.		
Design Facility	A facility with personnel who use design software, intellectual property blocks, supporting computer systems, and other information technology to create integrated circuit designs.		
Export Controls	1) Regulations administered by the Bureau of Industry and Security (BIS), U.S. Department of Commerce governing the export of dual-use technologies; 2) International Traffic in Arms Regulations (ITAR) administered by the U.S. Department of State governing products and services provided specifically for defense applications.		
Foundry	For the purpose of this survey a foundry is considered to be a facility that manufactures integrated circuit products for outside organizations as a business. Foundries are: 1) businesses dedicated solely to manufacturing integrated circuit products for fabless integrated circuit companies and other businesses; and/or 2) organizations that chiefly design and manufacture their own integrated circuit products, but that also operate a business of manufacturing IC products for other entities for a fee.		
Full Time Equivalent (FTE) Employees	Employees who work for 40 hours in a normal work week. Convert part-time employees into "full time equivalents" by taking their work hours as a fraction of 40 hours.		
Integrated Circuit (IC)	Analog or digital devices that incorporate transistors, diodes, capacitors, resistors, and other circuit elements that are integrated on a single substrate (chip), typically silicon.		
Manufacturing	The production of a working integrated circuit product at a fabrication facility.		
Manufacturing Facility	A facility that transforms integrated circuit designs into integrated circuit devices using an array of fabrication equipment including photolithography, deposition, etch, wafer dicing, and testing tools. These facilities produce functioning die as an end-product, devices that may be built with electronics-grade silicon or compound semiconductor materials, including gallium arsenide, gallium nitride, indium phosphide, and others.		
Non-U.S. Company	For the purpose of this survey, a non-U.S. company is an organization (publicly traded, privately held, for profit, not-for-profit, or non-profit) that is domiciled at a location outside of the United States. Companies that are a business unit of a parent organization with legal domicile located outside of the United States are non-U.S. companies.		
North American Industry Classification System (NAICS) Code	A unique identifier for the category of product(s) or service(s) provided by an organization. Find NAICS codes at http://www.census.gov/epcd/www/naics.html		
Organization	A company, firm, laboratory, or other entity that owns or controls one or more U.S. establishment(s) capable of designing and/or manufacturing integrated circuit products. A company may be an individual proprietorship, partnership, joint venture, or corporation including any subsidiary corporation in which more than 50 percent of the outstanding voting stock is owned by a business trust, cooperative, trustee(s) in bankruptcy, or receiver(s) under decree of any court owning or controlling one or more establishment.		
Outsource	To obtain goods and/or services by contract from a supplier (domestic or foreign) outside the organization.		
Product/Process Development	Conceptualization and development of a product prior to the production of the product for customers.		
Research and Development	Basic and applied research in the engineering sciences, as well as design and development of prototype products and processes.		
Semiconductor	Elemental materials such as silicon and germanium (or compounds like gallium arsenide) that possess levels of electrical conductivity that are less than a conductor but greater than an insulator. The properties of these materials and similar ones can be manipulated to affect conductivity through temperature and/or the use of dopants.		
Service	An intangible product (contrasted to a good, which is a tangible product). Services typically cannot be stored or transported, are instantly perishable, or come into existence at the time they are bought and consumed.		
Single Source	An organization that is designated as the only accepted source for the supply of parts, components, materials, or services, even though other sources with equivalent technical know-how and production capability may exist.		
Sole Source	An organization that is the only source for the supply of parts, components, materials, or services. No alternative U.S. or non-U.S. based suppliers exist other than the current supplier.		
Supplier	An entity from which your organization obtains inputs, which may be goods or services. A supplier may be another firm with which you have a contractual relationship, or it may be another facility owned by the same parent organization.		
United States	The "United States" or "U.S." includes the 50 states, Puerto Rico, the District of Columbia, Guam, the Trust Territories, and the U.S. Virgin Islands.		
Wafer Starts Per Week	The number of semiconductor wafers that can be processed by an integrated circuit production line in a 7-day period.		
BUSINESS CONFIDENTIAL - Per Section 705(d) of the Defense Production Act			